

INFORMATION DISCLOSURE STATEMENT

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| Applicant | : | Hirayama et al. |
| App. No | : | 10/590,046 |
| Filed | : | June 15, 2007 |
| For | : | BASE MATERIAL FOR PATTERN-FORMING MATERIAL, POSITIVE RESIST COMPOSITION AND METHOD OF RESIST PATTERN FORMATION |
| Examiner | : | Johnson, Connie P. |
| Art Unit | : | 1795 |
| Conf No. | : | 5635 |

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Enclosed for filing in the above-identified application is a PTO/SB/08 Equivalent listing 6 (six) references, of which 6 (six) are enclosed/submitted.

This Information Disclosure Statement is being filed before the mailing date of a final action and before the mailing of a Notice of Allowance. This Statement is accompanied by the fees set forth in 37 C.F.R. § 1.17(p). The Commissioner is hereby authorized to charge any additional fees which may be required or to credit any overpayment to Account No. 11-1410.

Respectfully submitted,

KNOBBE, MARTENS, OLSON & BEAR, LLP

Dated: August 25, 2010

By:

/Neil S. Bartfeld/

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